

High-Efficiency 'Receiverless' Optical Interconnects



Objective

Develop novel, high-efficiency, high-power, and high-speed transmitter and receiver modules to minimize additional support electronics in chip-to-chip optical interconnects

Unique features

- **Transmitter:** Small footprint integrated laser-modulator; high- κ grating; 45-degree facet for vertical; backside microlenses; quantum-well intermixing (QWI) for multiple-bandgaps
- **Receiver:** Digital receiver architecture; high-saturation power PDA photodetector design; crosstalk shielding

Approach

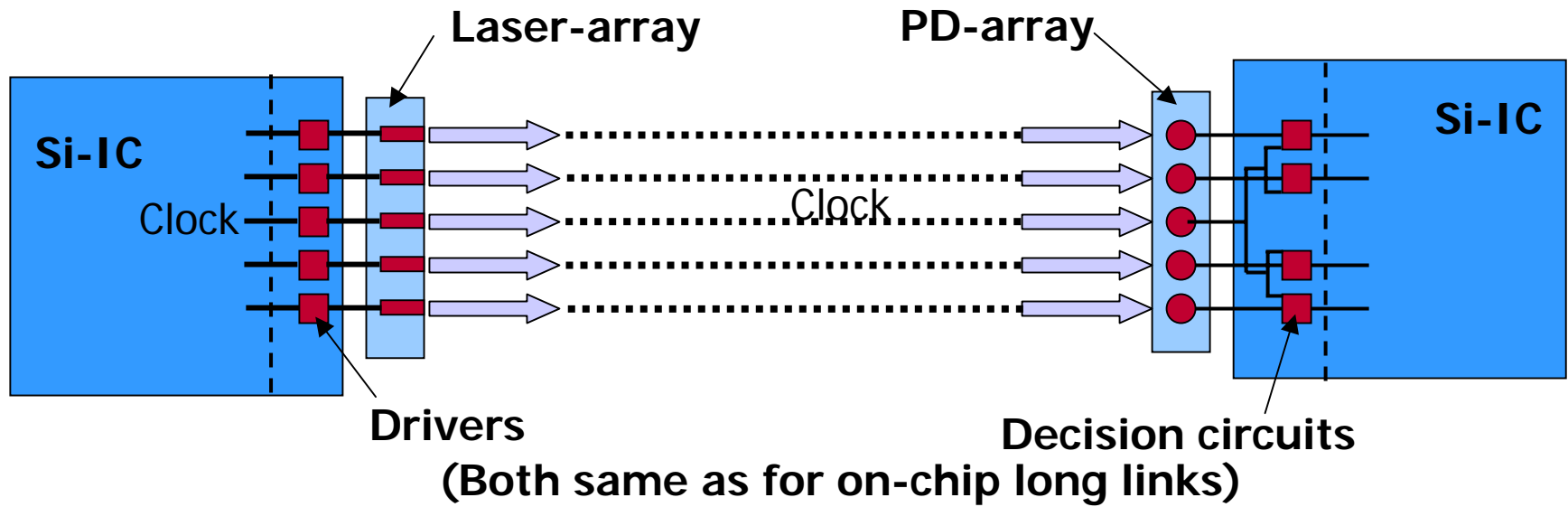
- Design & simulate transmitter and receiver modules
- Refine new technologies such as QWI, 45-degree facets, microlenses, air-bridge contacts, and shielding
- Fabricate & test device arrays
- Provide samples to industrial collaborators.
- Re-spin designs to respond to system's needs; fabricate & deliver new modules

Milestones—Phase I

- Design and simulate to verify power budget and other aspects 6 mo.
- Demo high-efficiency, high-power laser-mod and photodetectors 15 mo.
- Demo module arrays and deliver samples 18 mo.



Interconnect architecture



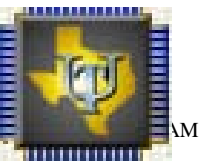


Criteria

- Support data rates up to 40 Gbs
- Small footprint and low power dissipation

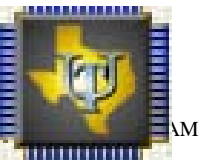
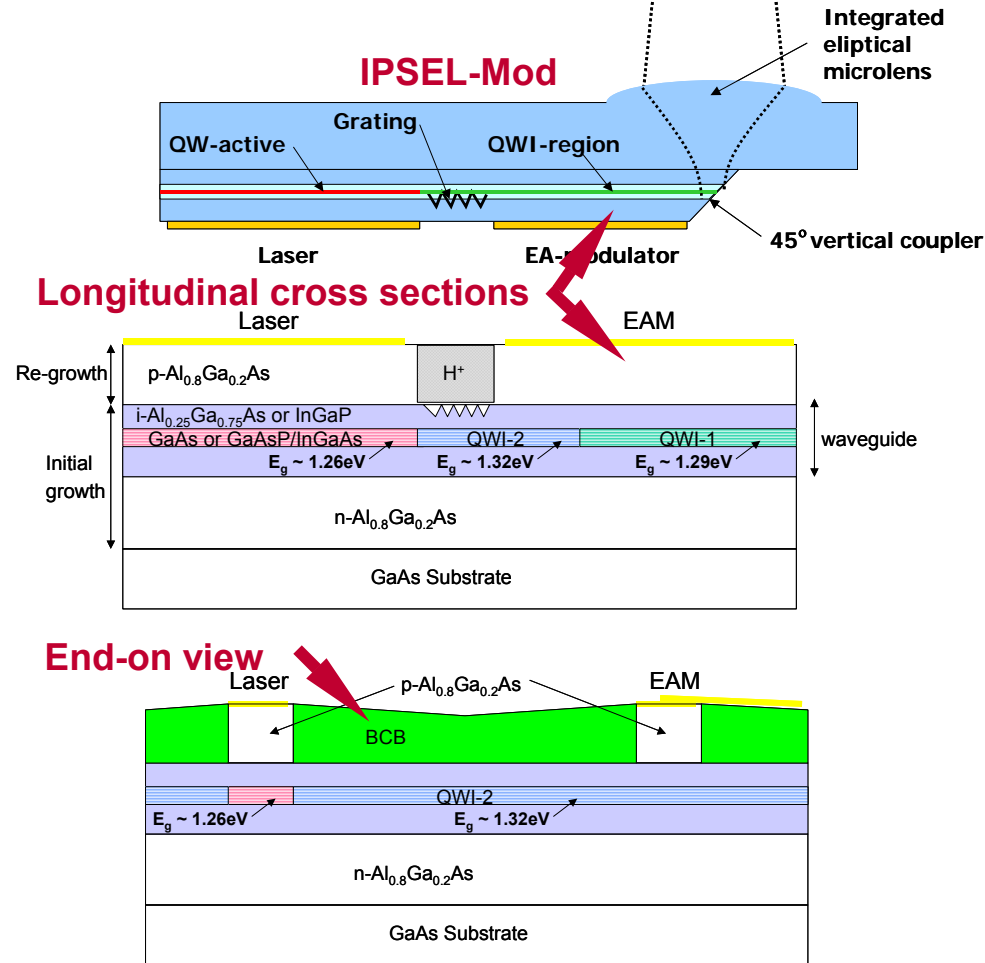
Concepts

- Avoid additional driver/receiver electronics
- Use integrated in-plane laser-modulator at ~ 980 nm to get bandwidth and power required at high efficiency
- Use high saturation power photodetector to directly drive logic (or same Si receiver as used for electrical interconnects)



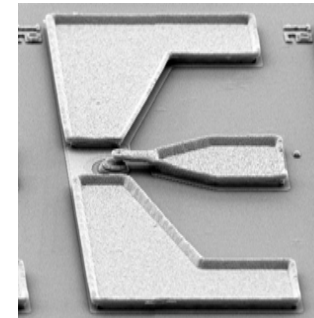
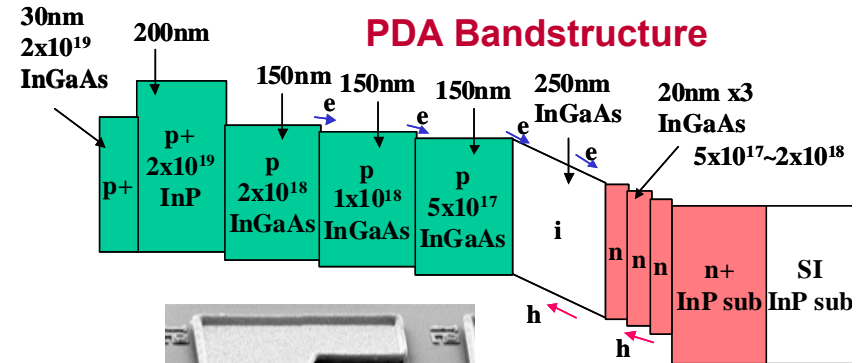


- Single-regrowth, small-footprint integrated DBR-laser--EA-modulator design
- High- κ grating to minimize footprint and loss
- 45-degree facet for vertical emission and no reflections
- Backside microlenses
- Quantum-well intermixing (QWI) for multiple-bandgaps to simultaneously optimize laser, grating, and modulator sections

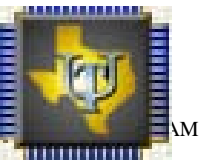
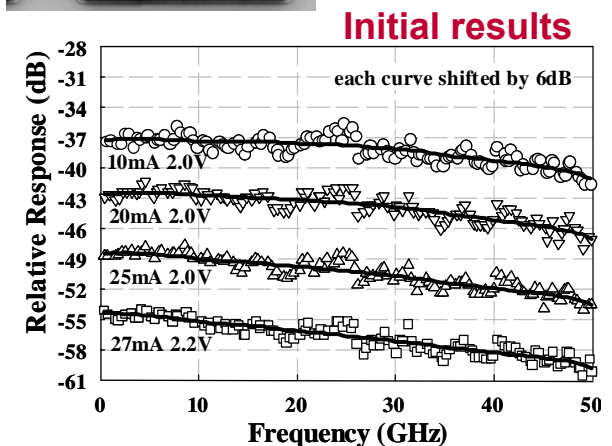


Technical Approach: Receiver

- Digital receiver architecture to eliminate receiver electronics and associated latency, noise and dissipated power
- High-saturation-power PDA photodetector design to deliver high currents at high bandwidths
- Air-bridge contacts for low stray capacitance
- Crosstalk shielding to eliminate effect of stray light



Air-bridge contacts



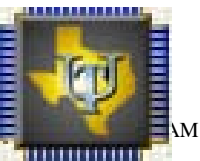


Active-Passive Integration

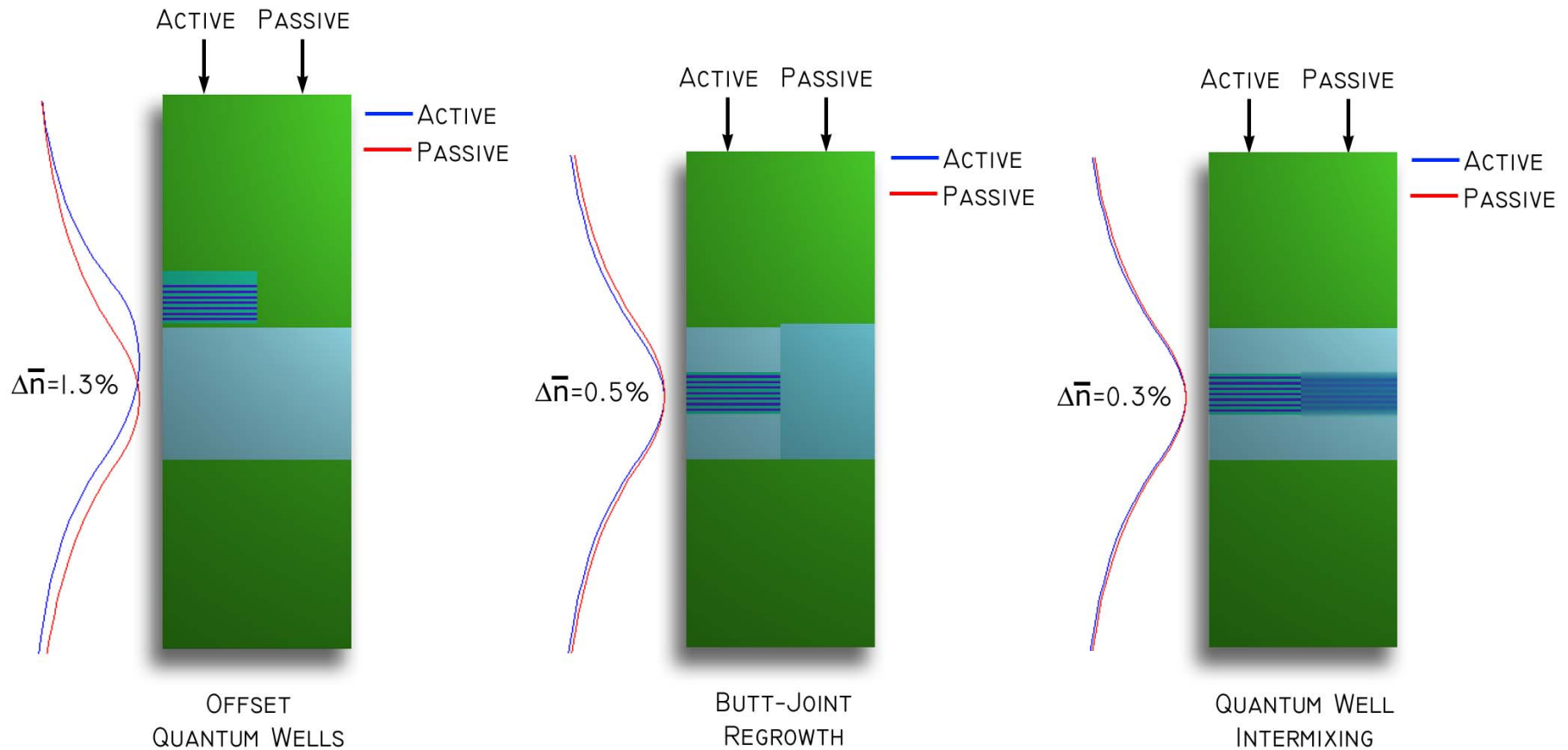
Modulators

Quantum-well intermixing

VCSELs/Microlenses

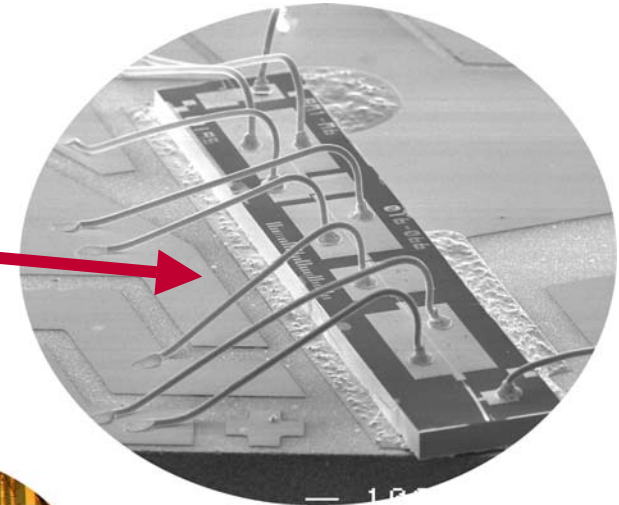
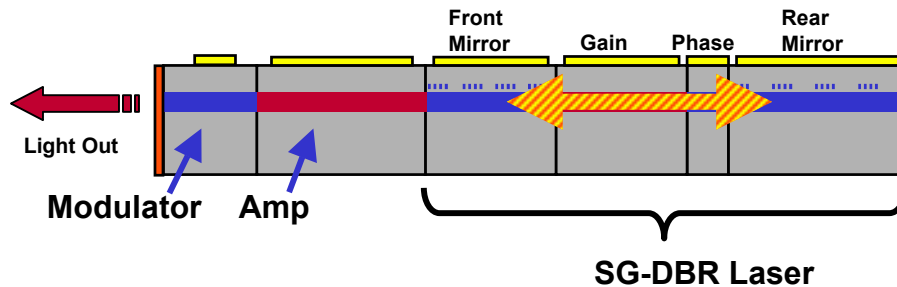


Active-passive integration



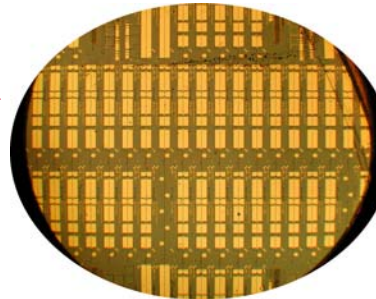
Commerical SGDBR-SOA-EAM

- Single-chip integrated tunable laser and modulator
- Common waveguide throughout



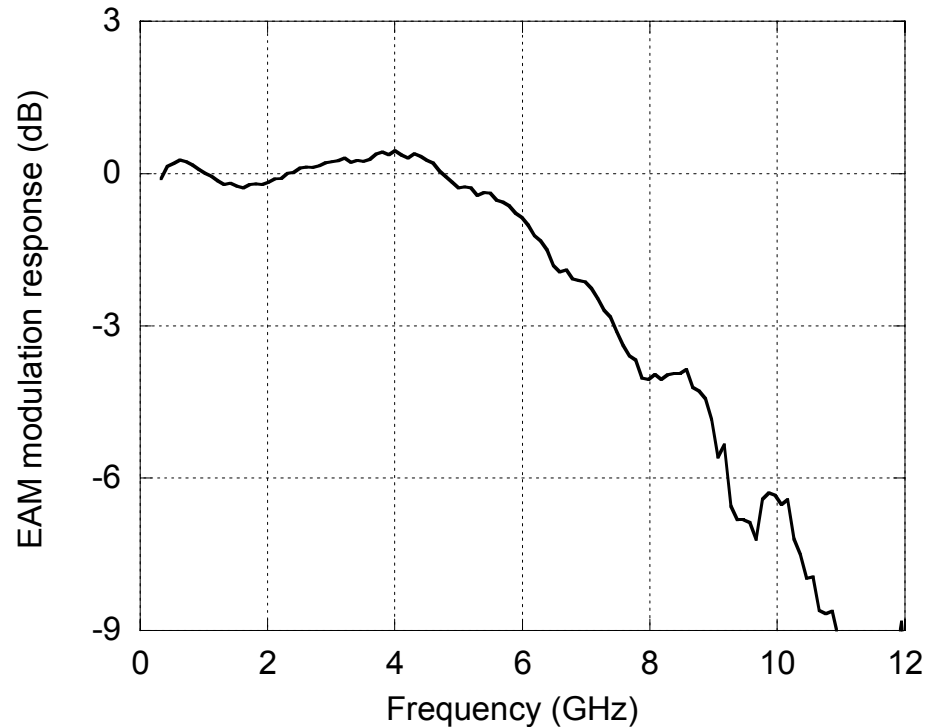
6 section InP chip

- On Wafer Testing

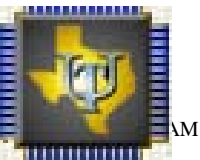


- ✓ High yield
 - Will be more like semiconductor ylds

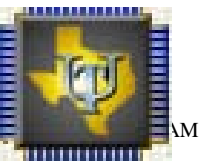
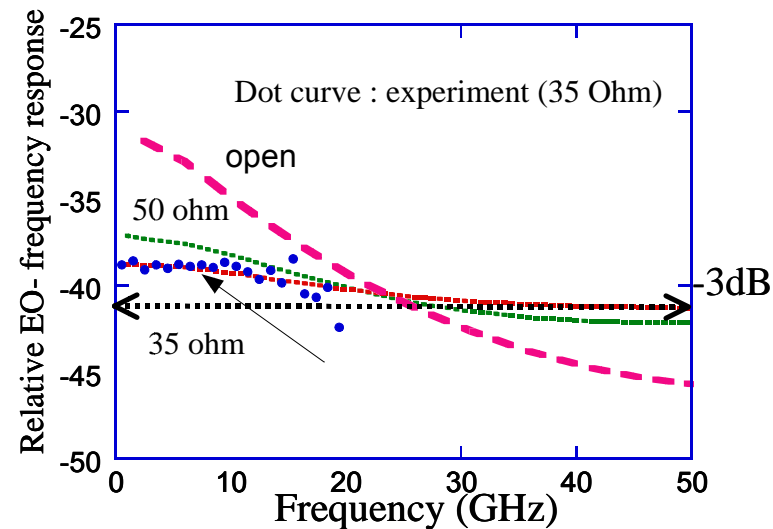
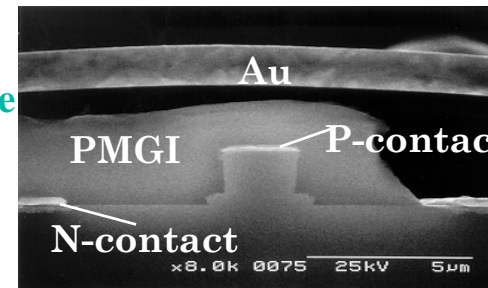
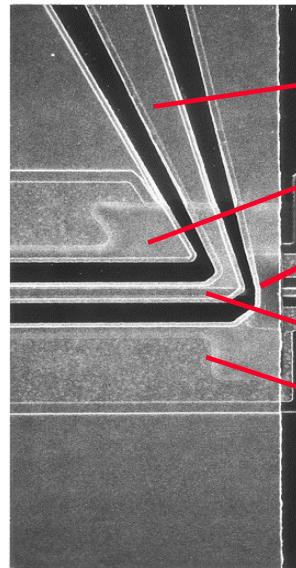
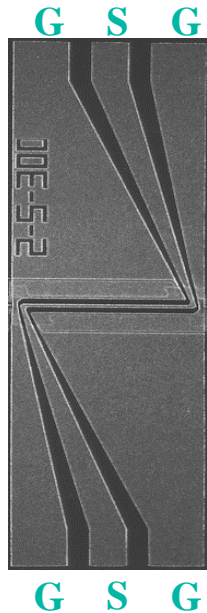
Lumped EAM modulator performance



➤ Typical bandwidth measurement for a lumped 250 μ m long device



Traveling-wave EAM



Quantum Well Intermixing

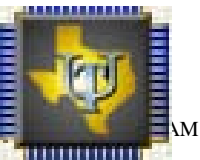
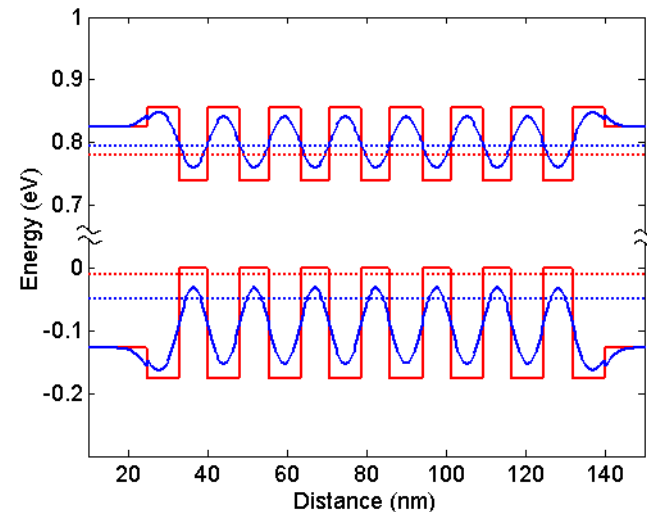
- Impurity-free vacancy-enhanced quantum-well-intermixing

■ Theory

- Create vacancies
- Thermal process to diffuse vacancies
- Diffusing vacancies allow atoms to exchange positions
- Smears the well/barrier interface, increasing the quantized energy level

■ Methods

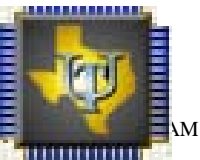
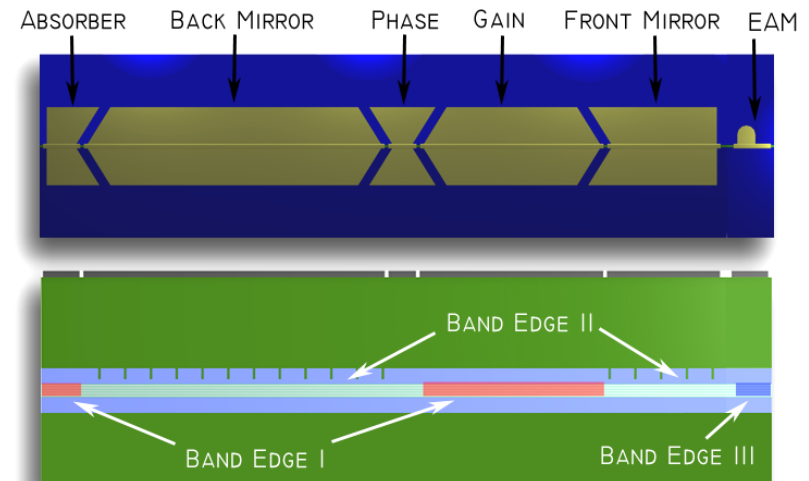
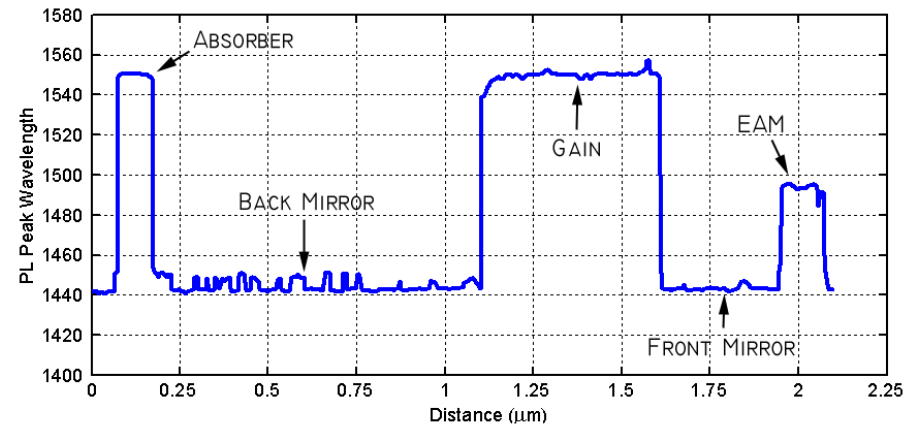
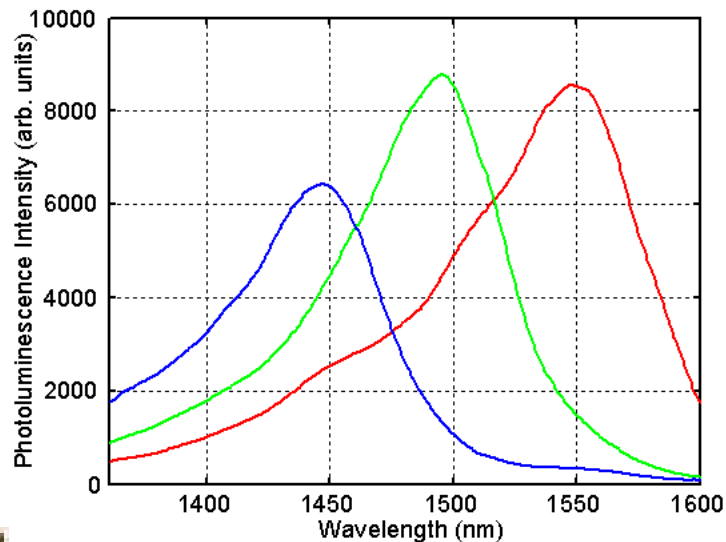
- Ion implantation, sputtering
- Rapid thermal anneal, laser induced



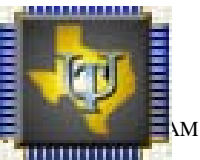
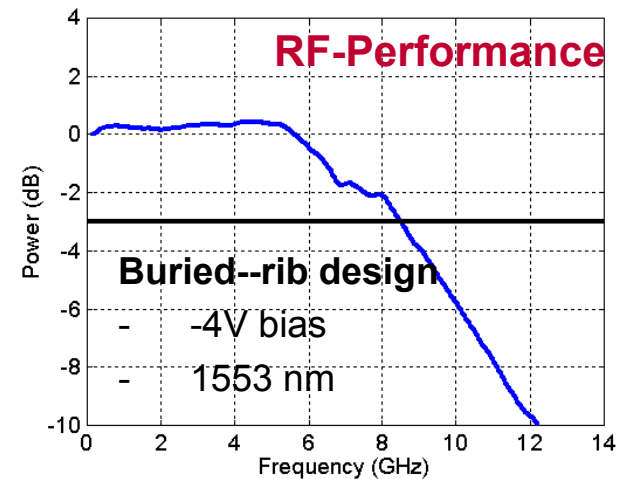
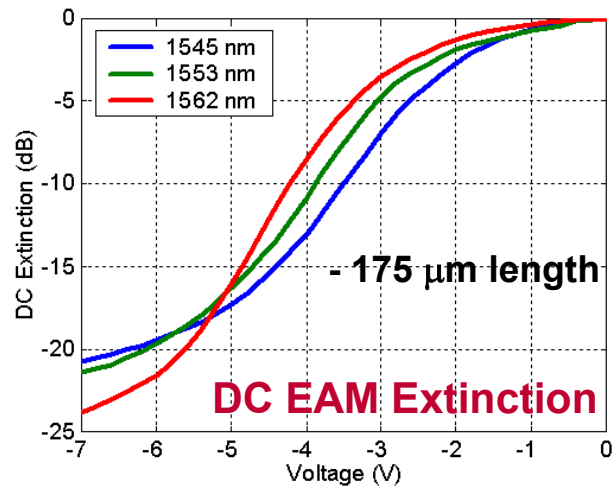
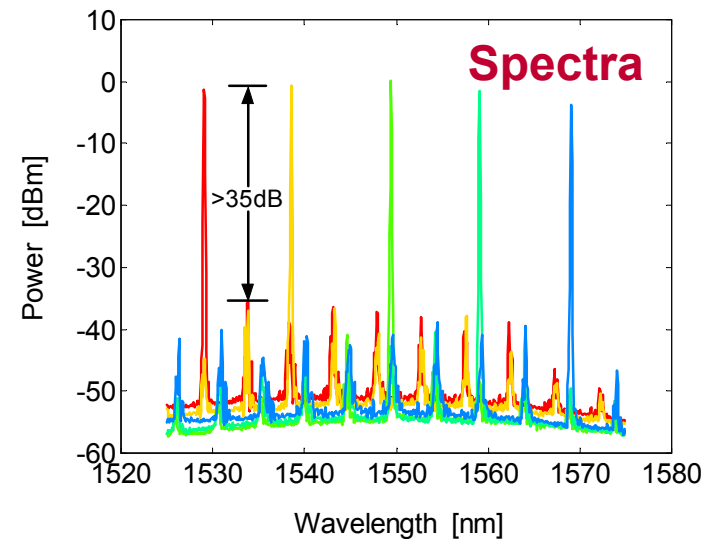
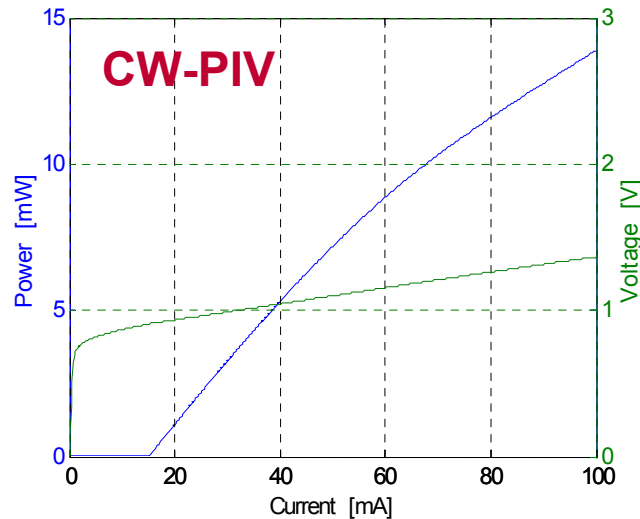
QWI-SGDBR with Integrated EA-Modulator (3 bandgaps)



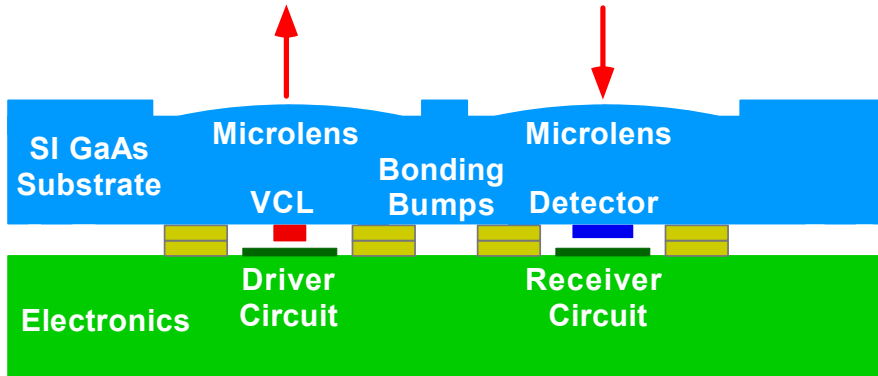
- Optimized band edges for various devices
- Three band edges across wafer
- Widely-tunable laser/EAM



QWI-SGDBR-EAM Transmitter Results



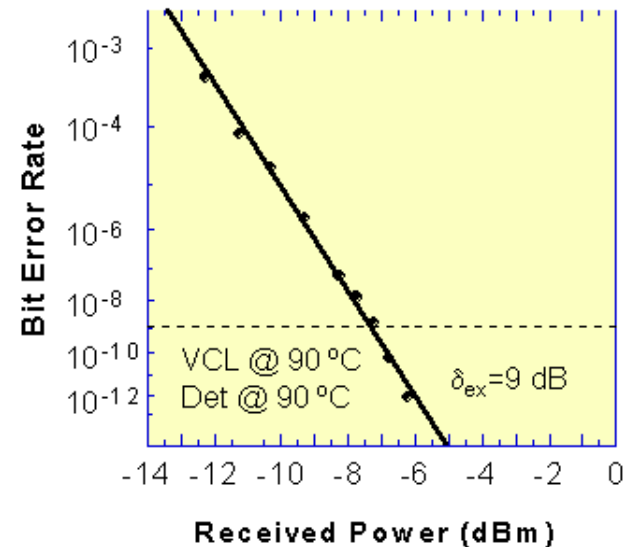
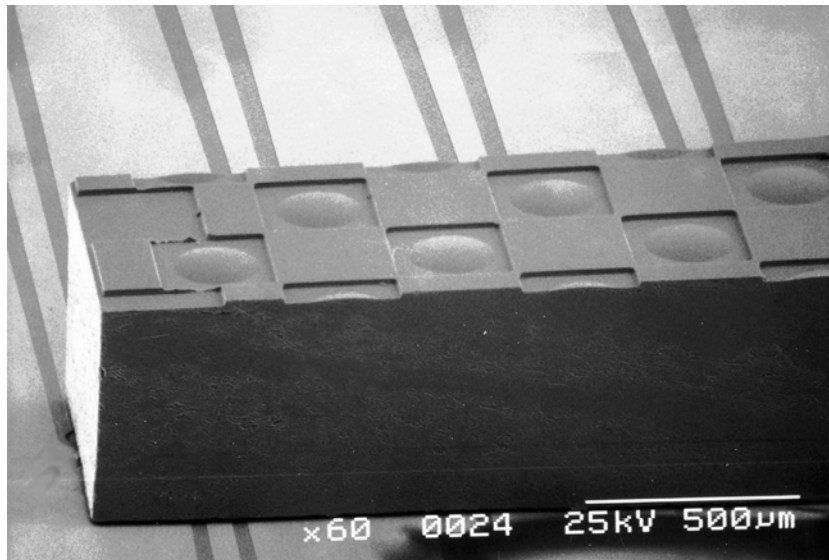
VCSELs for Optical Interconnects



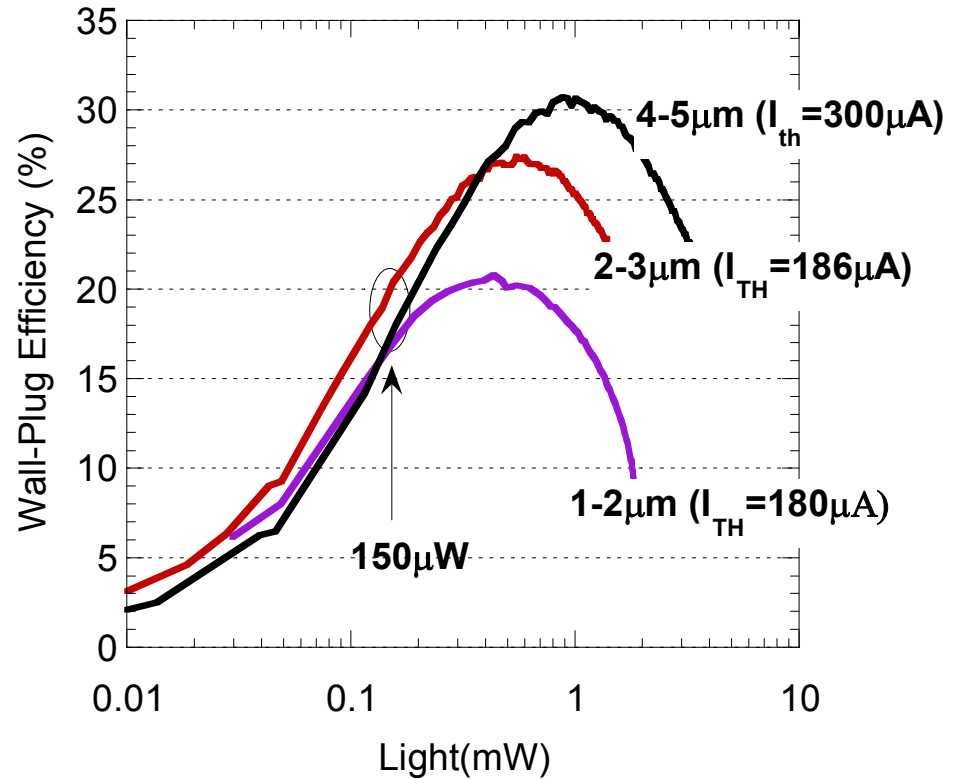
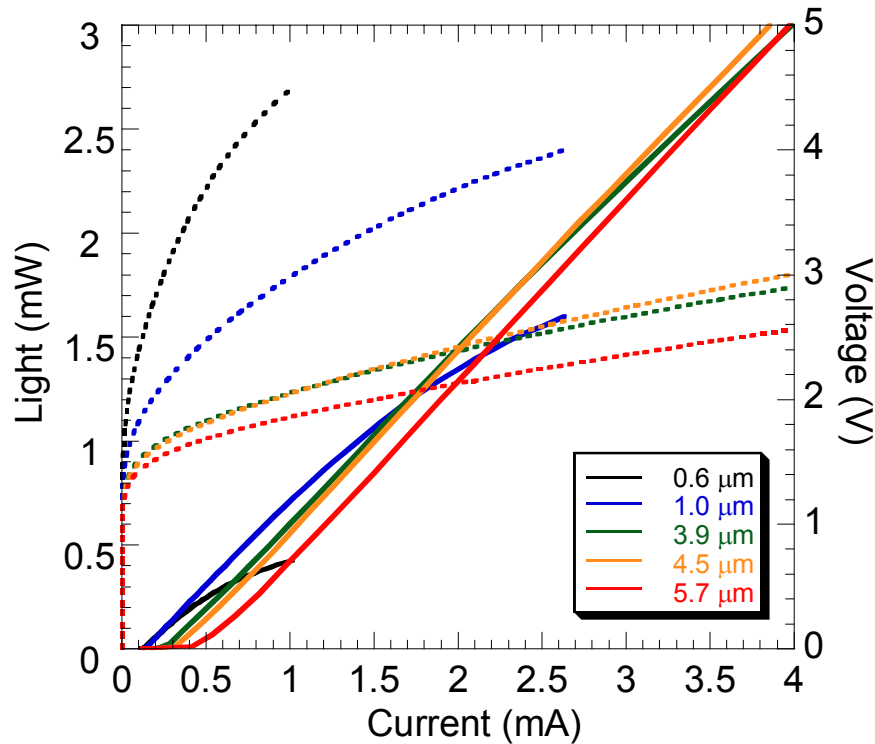
- Prior work has demonstrated state-of-the-art VCSELs and RC-PDs for free-space interconnects

- Microlenses eliminate or relax tolerances on external optics

- Error-free links from 0 – 90C

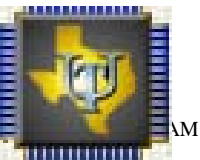


980 nm VCSEL P-I-V & Power efficiency



- Thresholds of 125 μA for 0.6 μm devices
- Optical losses almost eliminated with tapered apertures at the 1st null

- Wall-plug of 30% at 1mW output power



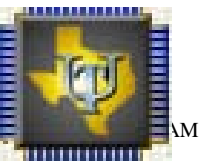
Progress on C2OI

- **Transmitter:**

- Waveguide design work nearing completion--initial laser optimization studies initiated
- QWI for Al-free actives on GaAs initiated--experimental work begun
- Laser-modulator axial design work initiated—need data for intermixed EAMs

- **Receiver:**

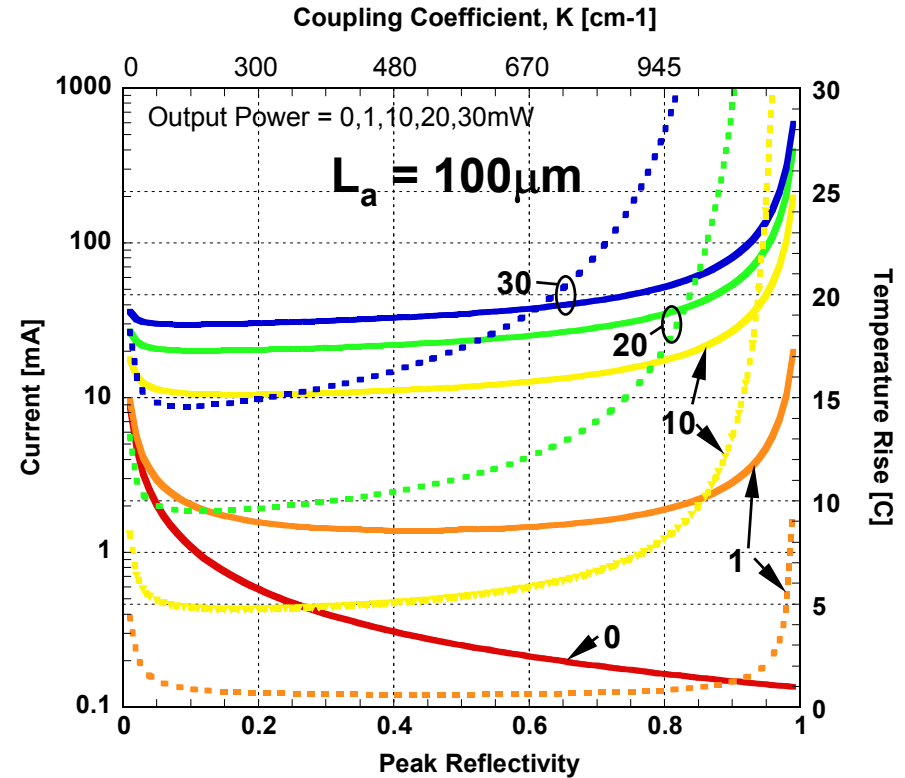
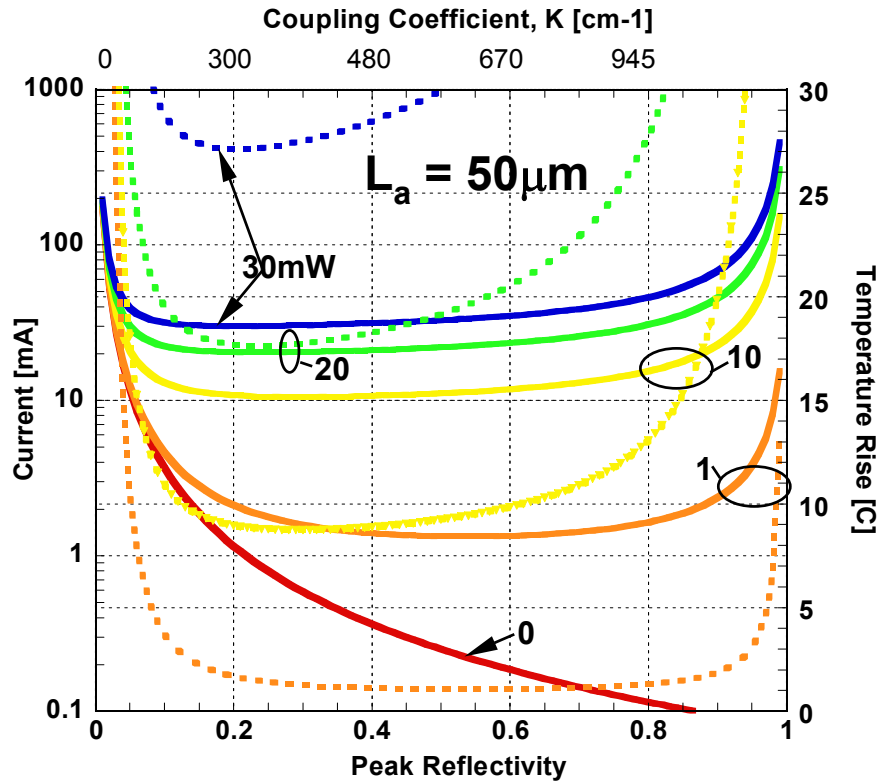
- Digital receiver architecture investigation begun
- First generation high-saturation-power PDA photodetector design complete
- Initial demonstration of concept completed.



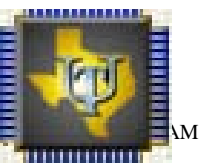
Transmitter Design:

Current and Temp rise for Constant Powers

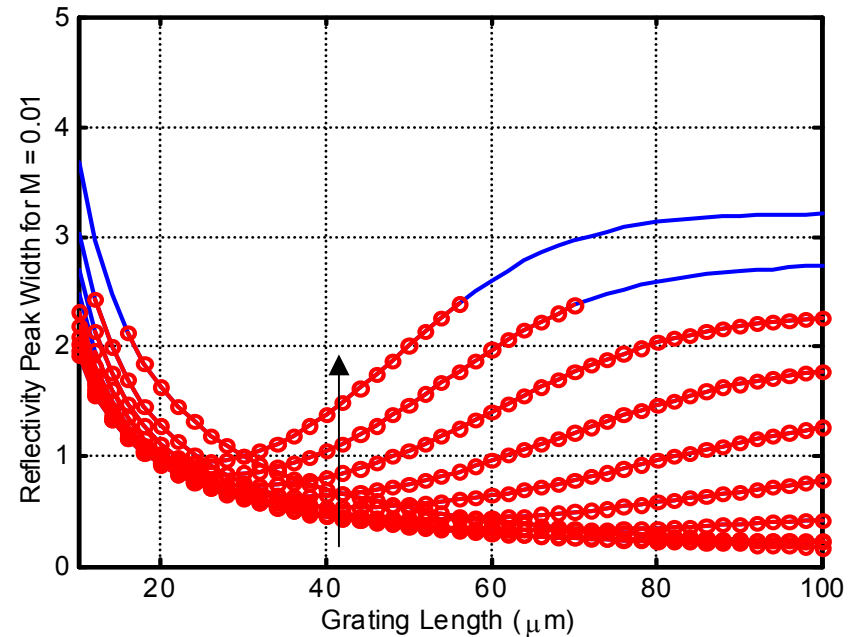
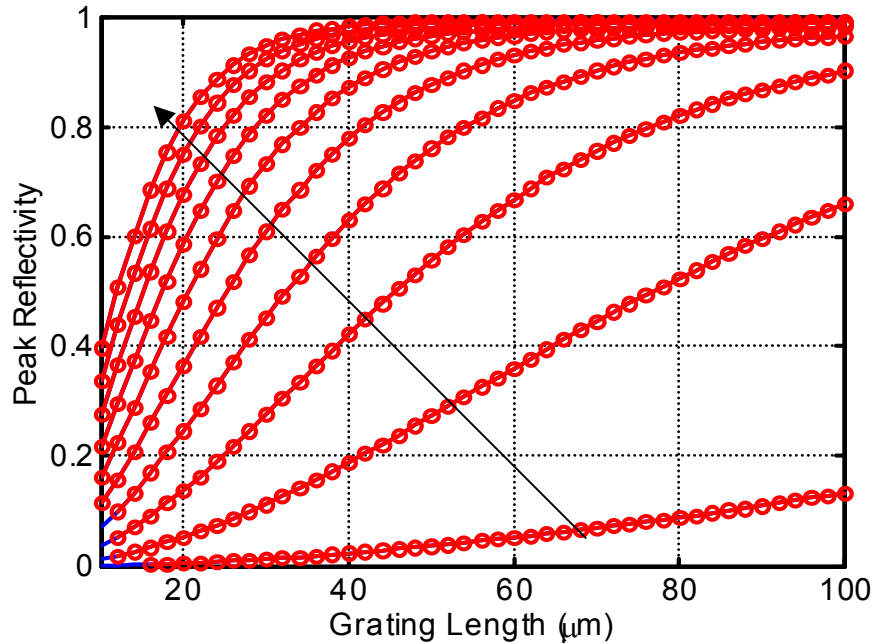
Required current (solid) and Temperature Rise (dotted) vs. Front Mirror Reflectivity for $L_g = 20\mu\text{m}$



Design Curves for $W = 2\mu\text{m}$, $N_{qw} = 3$, $R_b = 90\%$, $\eta_i = 90\%$,
 $\alpha_{ia} = \alpha_{im} = 5\text{cm}^{-1}$, $\Gamma g_o = 50\text{cm}^{-1}$

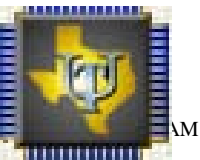
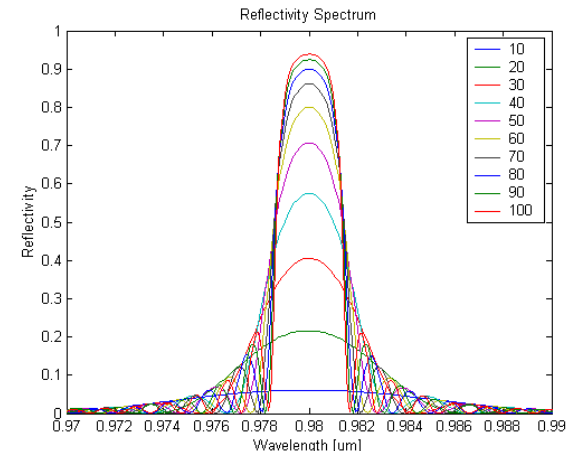


DBR Mirror Design



Red indicates designs for SMSR $\geq 30\text{dB}$

For increasing kappa 50:100:950 cm^{-1}



GaAs Lattice-Matched Bandgaps

- Offsets in **blue** #s to GaAs
- Bandgaps in black
- Units are meV

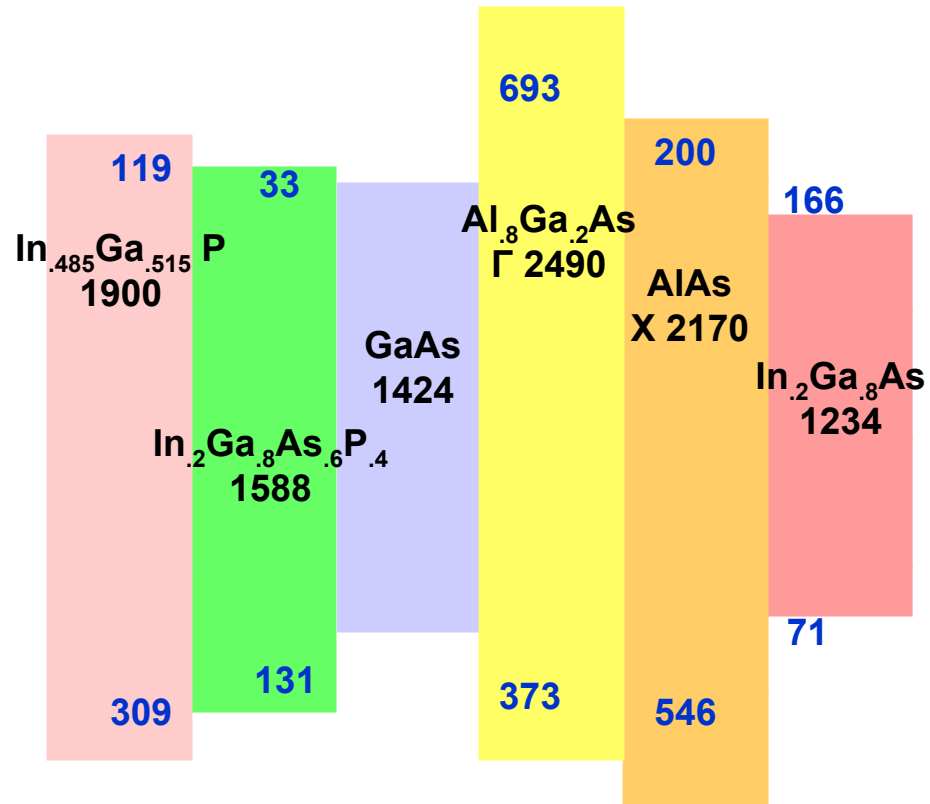
Offsets to GaAs

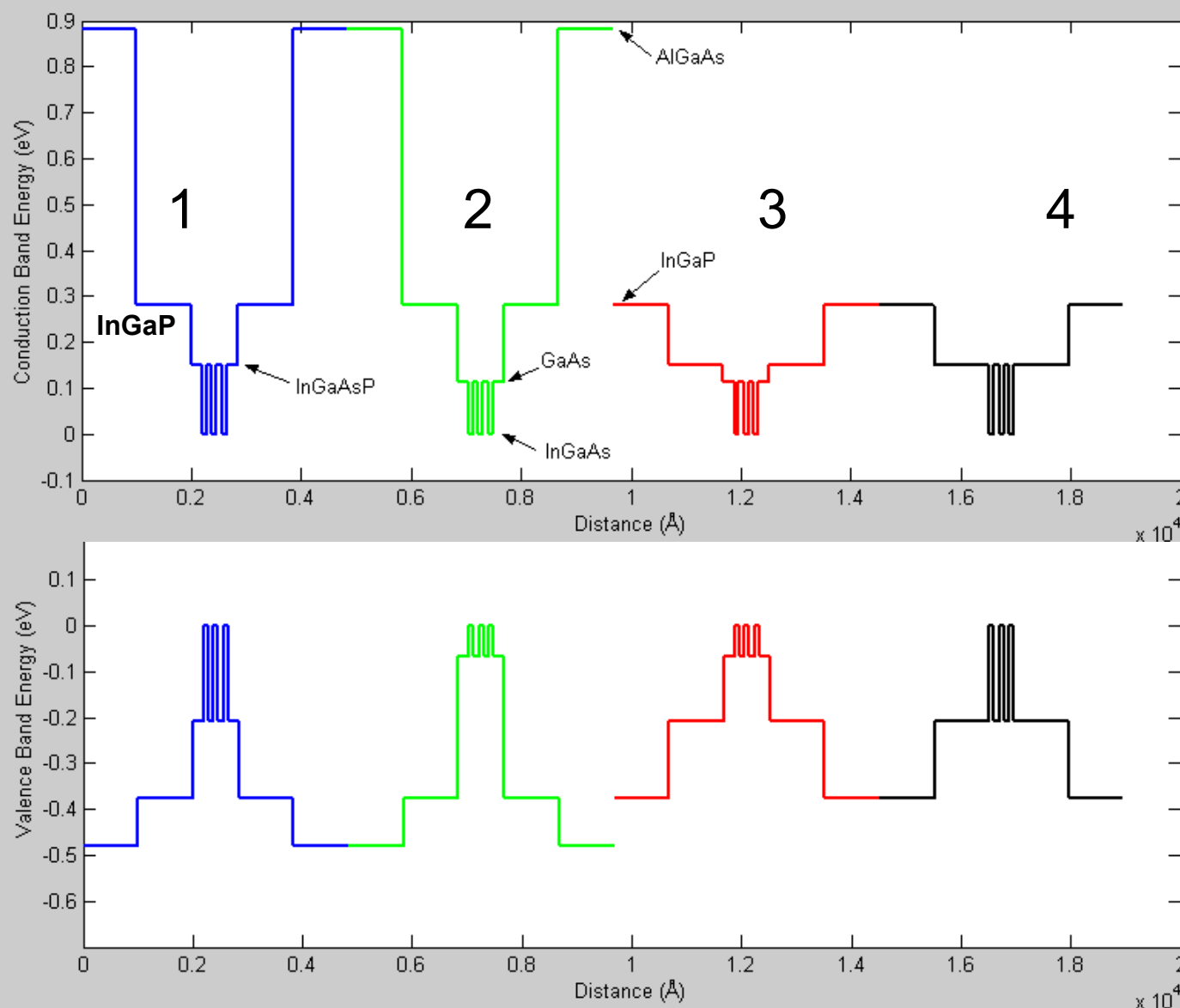
$$\text{In}_{.2}\text{Ga}_{.8}\text{As } \Delta E_C = .628 \Delta E_g$$

$$\text{In}_{.2}\text{Ga}_{.8}\text{As}_{.6}\text{P}_{.4} \Delta E_C = .2 \Delta E_g$$

$$\text{In}_{.485}\text{Ga}_{.515}\text{P } \Delta E_C = .35 \Delta E_g$$

$$\text{Al}_{.80}\text{Ga}_{.20}\text{As } \Delta E_C = .65 \Delta E_g$$

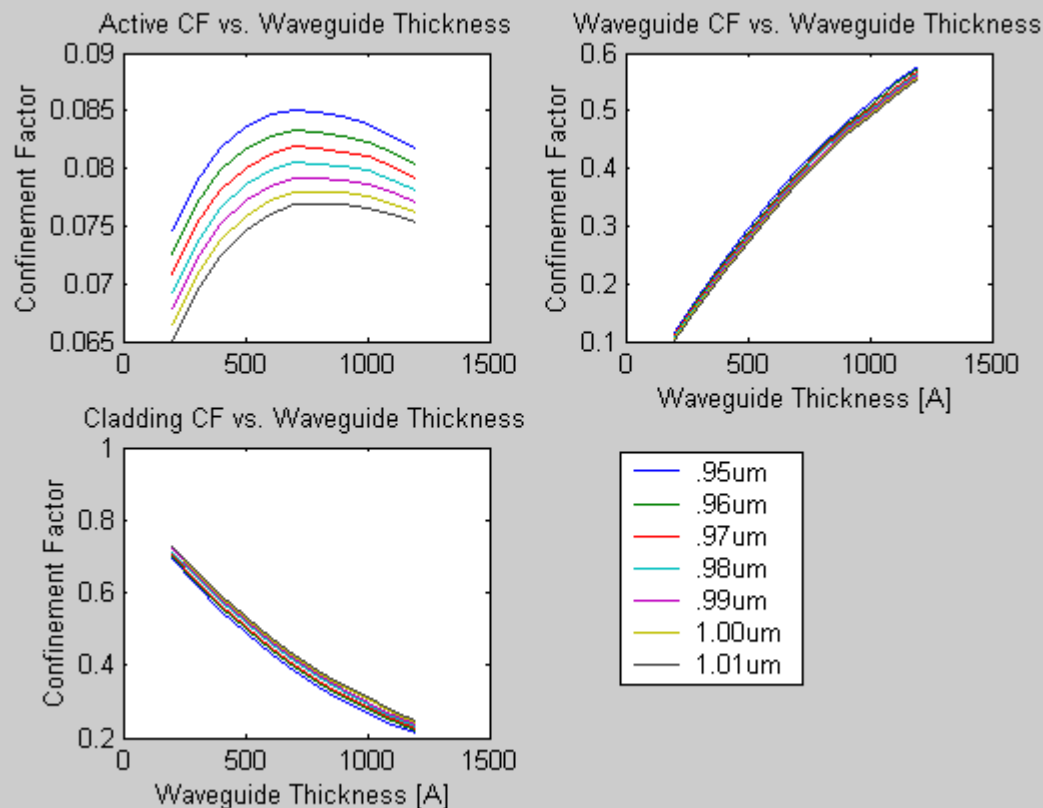
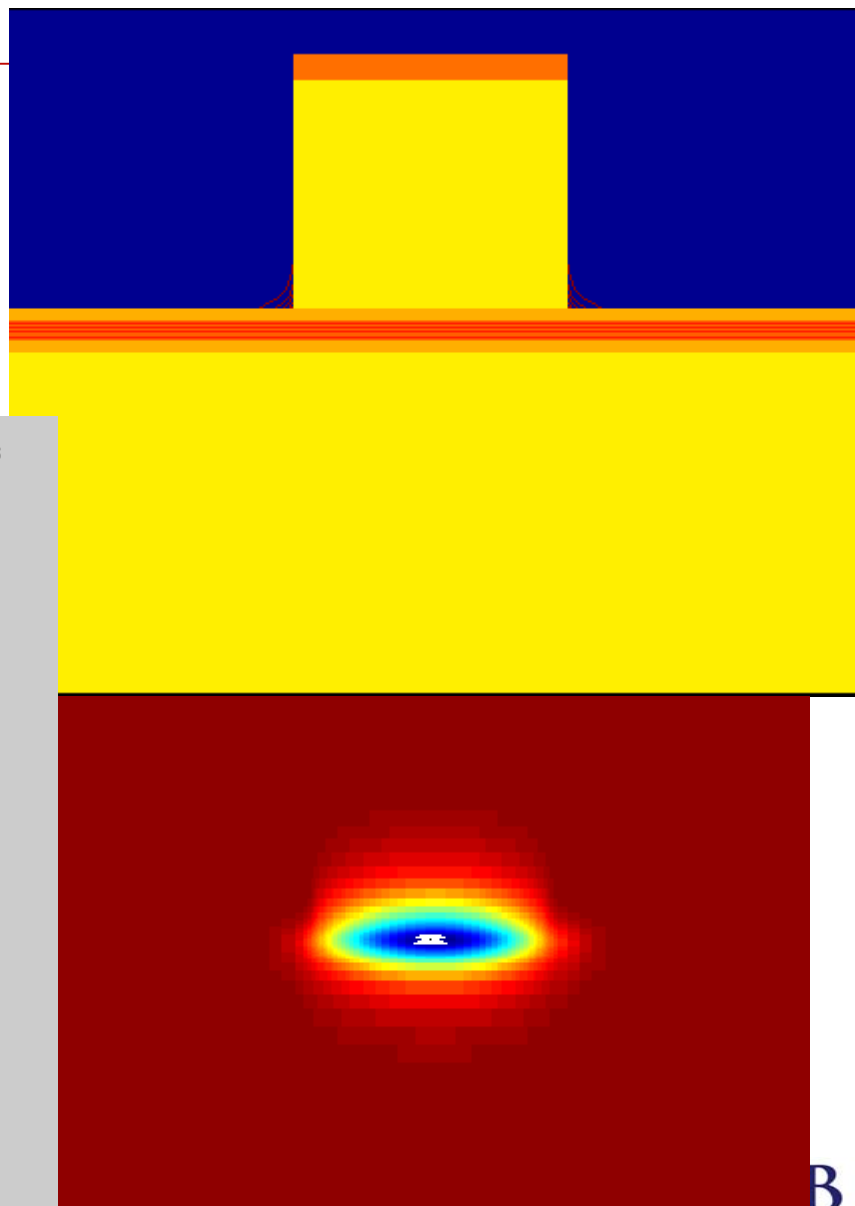




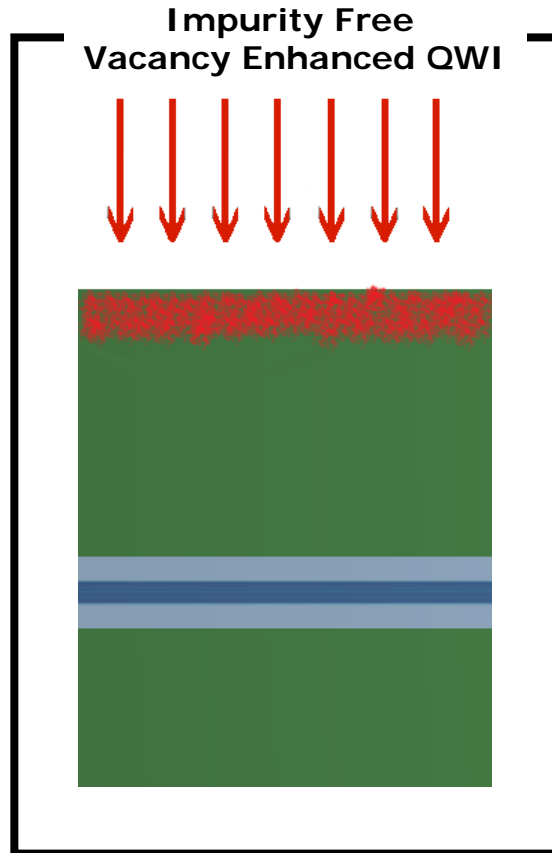
Optimize Waveguide Thickness

Design #1, 3 QWs, 2.0 μm ridge
75 \AA Wells, 80 \AA Barriers

Top and Bottom Half of WG = 700 \AA each



Future QWI Process



P⁺ Implant into 4500Å InGaP sacrificial layer.

RTA to drive vacancies into Active Region to intermix quantum wells.

Etch off sacrificial layer.

Regrow top cladding.



- **Transmitter (UCSB):**

- Design & simulate small footprint IPSEL-Mod 6 mo.
- Demo laser-mod ($P_o > 10$ mW; $f_c > 15$ GHz) 15 mo.
- Demo 4-element array module and deliver samples 18 mo.
- Demo efficient 40Gb/s IPSEL-Mod array module and deliver samples 36 mo.

- **Receiver (UT-Austin):**

- Design & simulate PDA and digital receiver 6 mo.
- Demo PDA ($P_{sat} > 10$ mW; $f_c > 40$ GHz) 15 mo.
- Demo 4-element array module and deliver samples 18 mo.
- Demo efficient 40Gb/s digital receiver array module and deliver samples 36 mo.

